

Innovation Frontline™

Mining Innovations



Products Overview



What is Innovation Frontline™?

- Innovation Frontline™ is an in-depth research report on the technology innovations landscape.
- Innovation Frontline™ is based on the statistical and analytical methods for mining patent information.
- Research for RFID Innovation Frontline™ is done by an expert both in intellectual property (IP) and technology subject matter.

What's in Innovation Frontline™?

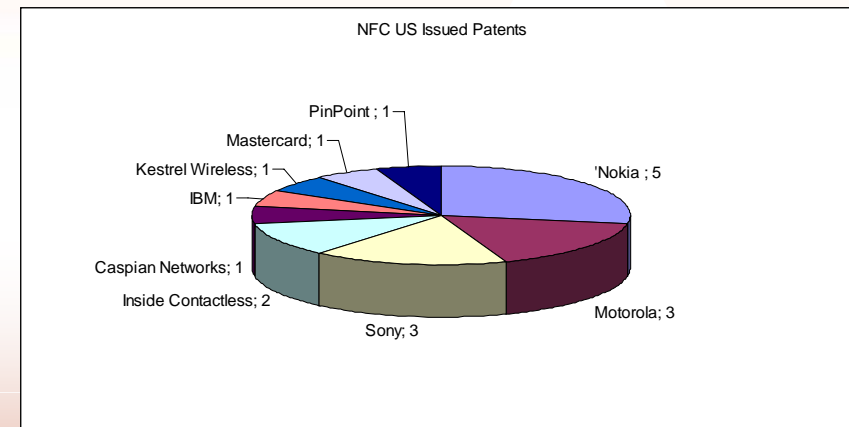
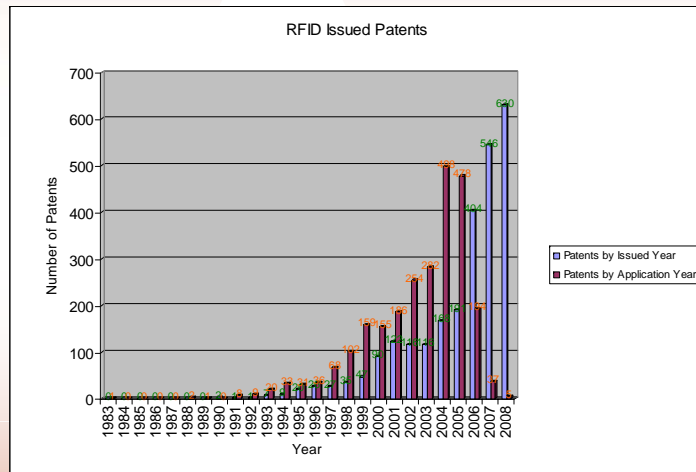
- IF Statistics™ shows technology innovations landscape from the statistical analysis of bibliographical patent information .
- IF Analytics™ shows the technology innovations landscape from the in-depth quantitative and qualitative analysis of patent information.
- IF Enterprise™ shows the technology innovations landscape for specific companies.

Utilization of Innovation Frontline™

- Trend analysis for technology/product/market forecasting.
- Planning technology/business strategy.
- Competitive Intelligence for a specific industry.
- IP strategy for R&D.
- Opportunity analysis for technology licensing.

IF Statistics™

- Number of issued patents/published applications by application and issued year.
- Ranking information by assignee (or inventor), nationality, UPC (or IPC), patent families, and citations.

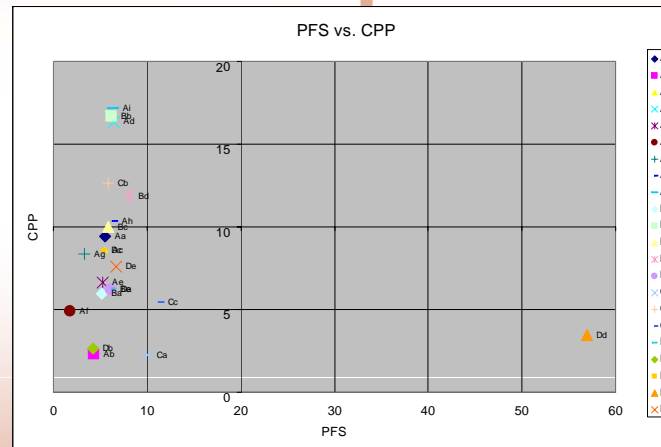
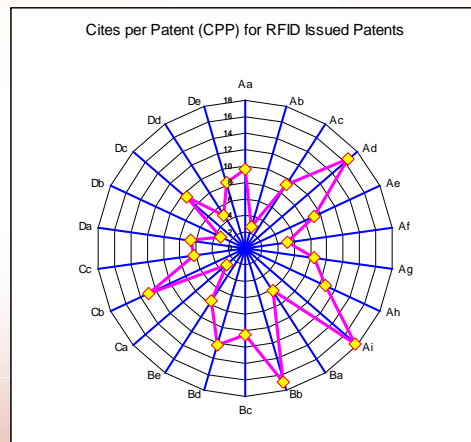


Trends and Ranking

IF Analytics™



- Top assignees' patent portfolios by customized technology classifications.
- Innovation indexes such as cites per patent and patent family size.
- Technology development snapshot for a focused field of technology.



6952317
Fanchel
Semiconductor

2003
2005

Self-compensating antennas for substrates having differing dielectric constant values

An RFID tag or label includes a wireless communication system that is mounted in electrical proximity to the dielectric material. The wireless communication system includes a wireless communication device associated with an antenna system that has at least one conductive lobe, including a plurality of electrical components forming an impedance matching network, coupled to the conducting lobe and wireless communication device, that electrically interact with the dielectric material to maintain a substantial impedance match between the antenna system and the wireless communication device; and/or a structural element forming a frequency selective by-pass trap circuit formed in the conducting lobe, and electrically interacting with the dielectric material to maintain a substantial impedance match. The antenna system may be directly mounted on a dielectric substrate, which serves as the dielectric material, or alternatively may be mounted on a backing layer intermediate the dielectric substrate and the antenna system.

FIG. 6A

FIG. 11

Antenna system for radio frequency identification

An antenna including an electrically conductive portion defined substantially by a self-similar geometry present at multiple resolutions. The electrically conductive portion includes two or more angular bends and is configured to radiate broadband electromagnetic energy. The antenna further includes an electrically non-conductive portion that structurally supports the electrically conductive portion.

6905122
Fractal Antenna
Systems

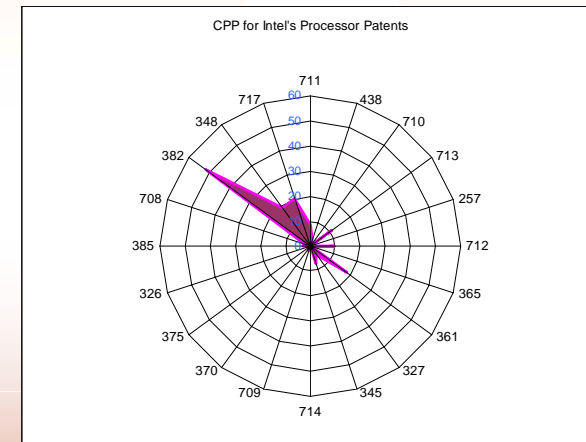
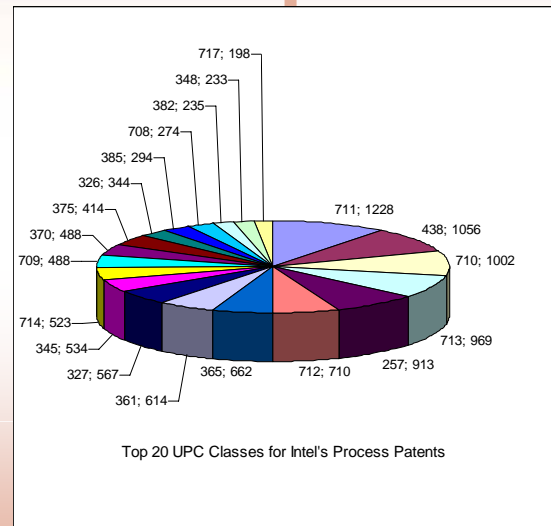
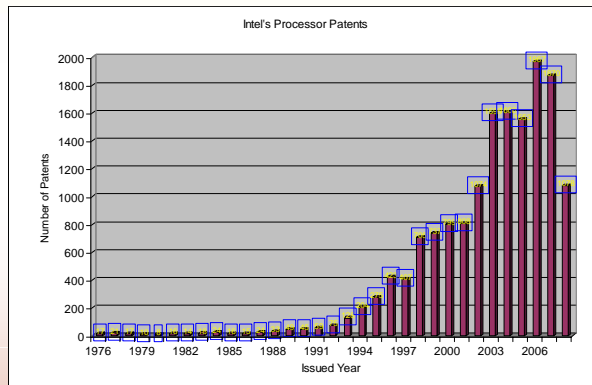
2004
2006

Tech. and Innovation

IF Enterprise™

IF Enterprise™ shows the technology innovations landscape for specific companies. In addition to all the contents in the IF Statistics™ and IF Analytics™, IF Enterprise™ can include analysis for a specially requested research by customers:

- Duo diligence & Strategy for the patent portfolio development



**Intel's
Processor Innovations**

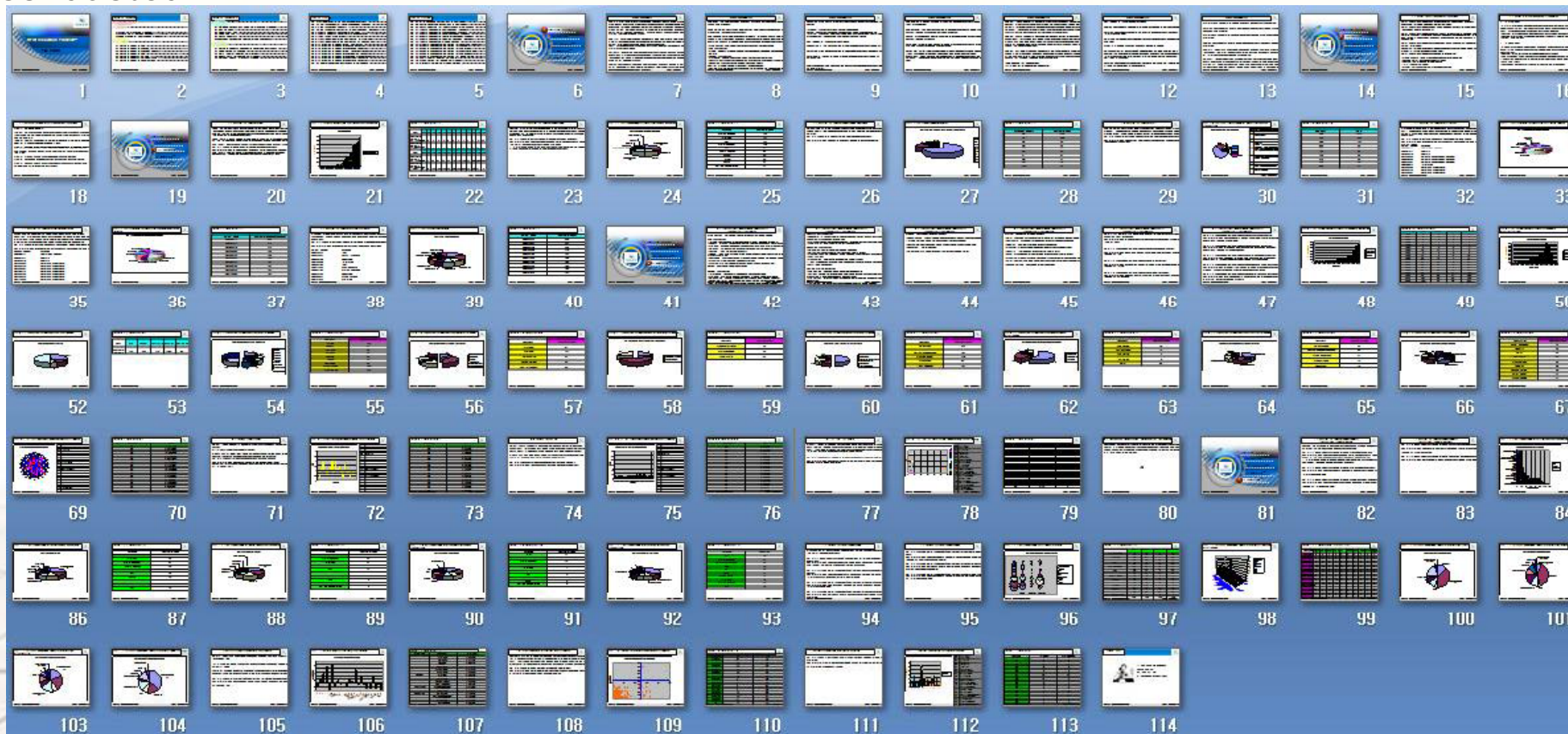
RFID Innovation Frontline™



RFID Innovation Frontline™ is a research report on the technology innovations landscape for Radio Frequency Identification (RFID).

RFID Innovation Frontline™ utilizes patent information to assess the state of the art for technology innovations in RFID.

RFID Innovation Frontline™ analyzes the utility patents issued in the United States (US) before January 1, 2009. Since the patent information are changed over time, this report only reflects the technology innovations landscape up to the time the analysis is conducted.



Thank you!



- If you have any questions please contact Dr. Alex G. Lee at alexglee@techipm.com